FW



		TRANSMITTAL LETTER		ETTER	Docket No. 4799-0111P	
Application No. 10/791,812-Conf. #3659		Filing Date		Examiner	Art Unit	
Applicant(s): Darrell A. BENTLE		March 4, 2004		A. Gilman	2833	
	DENSITY MUL	TI-PORT-MOI	DULE PATCH	PANEL SYSTEM		
MS Amendment Commissioner for F P.O. Box 1450 Alexandria, VA 223						
Transmitted herev	with is an ame	ndment in the	above-identif	ied application.		
The fee has been	calculated an	d is transmitte	d as shown b	elow.		
		CLAIM	S AS AMENI	DED		
	Claims Remaining After Amendment	Highest Number Previously Paid	Number Extra Claims Present	Rate		
Total Claims Independent	. 23	- 24 =	0			
Claims	3	- 3 =	0			
Multiple Depend	ent Claims (che	ck if applicabl	e)			
Other fee (please	specify):					
TOTAL ADDITION	ONAL FEE FO	R THIS AME	NDMENT:		0.00	
x Large Entity				Small Entity		
x No additional	fee is required	d for this amen	ıdment	,		
Please charg	e Deposit Acco	ount No.	in	the amount of \$	•	
	e amount of \$			he filing fee is enclos	a d	
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as described	s nereby autho below. A dupl	orized to charg icate copy of t	je and credit i his sheet is e	Deposit Account No.	02-2448	
	y overpayment					
			nrocossina fa	ees required under 37 (	OED 4.40 - 14.47	
1 / /	/ /)// V			es required under 37 (	JFK 1.16 and 1.17.	
Scott L. Lowe Attorney Reg. No	~ "	# 39,53	• 6	Dated: A	pril 26, 2005	
BIRCH, STEWAI 8110 Gatehouse Suite 100 East	RT, KOLASCH	& BIRCH, LL	P			
P.O. Box 747 Falls Church, Vir (703) 205-8000	ginia 22040-0	747				



## MS AMENDMENT PATENT 4799-0111P

## IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant:

Darrell A. BENTLEY

Conf.:

3659

Appl. No.:

10/791,812

Group:

2833

Filed:

March 4, 2004

Examiner: GILMAN, A.

For:

A HIGH-DENSITY MULTI-PORT-MODULE PATCH

PANEL SYSTEM

## **AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

April 26, 2005

Sir:

In response to the Examiner's Office Action dated January 26, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.